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Selective Protection of Either the Phenol or the Hydroxy Group in Hydroxyalkyl Phenols

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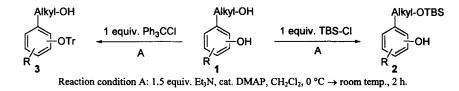
Abstract: Hydroxyalkyl phenols can be protected either at the hydroxy group or at the phenol in a simple protocol (CH₂Cl₂, Et₃N, DMAP, 0 °C \rightarrow room temp.) by using either t-butyldimethylsilyl chloride or trityl chloride as protecting reagent. Yields are in the range of 37–92%. © 1999 Elsevier Science Ltd. All rights reserved.

Selective protection and deprotection of functional groups is one of the major issues in multistep synthetic strategies of organic compounds. In particular, hydroxy groups are targets for selective protection, because often selectively accessible OH-groups are required for the following reaction. Many OH-protecting groups are known and the ability to protect a primary hydroxy group in presence of a secondary was found with a variety of protecting reagents.¹

As a part of our research program on photosensitive aromatic compounds, we required the selective protection of a primary hydroxy group in presence of a phenol in a salicyl alcohol derivative. A literature survey revealed only a few reports on the regioselective protection of hydroxyalkyl phenols.²⁻⁶ Perfluoroaryl derivatives,² allyl bromide,³ *t*-butyloxycarbonyl (Boc) anhydride⁴ and acetylimidazole⁵ were used to protect selectively the phenol, whereas tetrahydropyranyl ether were exclusively formed at the hydroxyalkyl group.⁶ However, silyl ethers were neither used to protect the hydroxy group nor the phenol selectively. Only a procedure for the selective deprotection of phenyl alkyl disilyl ether in each direction was described.⁷

In a first experiment, one equivalent of TBS-Cl was added to a solution of alcohol 1a, 1.5 equivalents of triethylamine, and a catalytic amount of N,N-dimethylaminopyridine (DMAP) in dichloromethane at 0 °C. After workup and purification we obtained the monoprotected silvl derivative 2a and diprotected compound in 82% and 8% yield, respectively (Table 1, entry 1). The silvl ether 2a proved to be incompatible with the following reaction conditions making a different protecting group for the alkyl-OH group necessary. We supposed that the trityl group would meet our requirement (sterically demanding protecting group selective for primary alcohols, stable under basic conditions). Thus, alcohol 1a was treated with 1.05 equivalent of trityl chloride under exactly the same reaction conditions as used for the silvl ether formation. To our surprise, phenol ether 3a was obtained in 78% (entry 6) and the diprotected compound in 12% yield (Scheme 1).

Scheme 1



Based on the experience with 1a, we turned our attention to the scope of this regioselective protection and subjected hydroxyalkyl phenols $1b-d^8$ and a heterocycle (kojic acid (4))⁸ to our protection protocol (Scheme 2). The results obtained are summarized in Table 1. With salicyl alcohol 1b the same reactivity pattern was observed as with the diazirine derivative 1a, indicating that possible electronic effects of the trifluoromethyl diazirine moiety have no influence on the outcome of the reaction. Silyl ether 2b and trityl ether 3b were

formed in 91 and 67% yield, respectively (entries 2 and 7). A neighbor group effect in 1a and 1b is also unlikely because dihydroconiferyl alcohol 1c having a hydroxyalkyl chain in *para*-position to the OH-group shows a similar behaviour. Silylation with TBS-Cl gave silyl ether 2c in 55% yield (entry 3), but trityl chloride was less selective affording compound 3c and the tritylated primary alcohol in a 10:1 ratio (66% yield, entry 8).



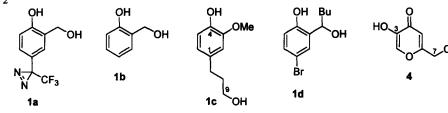


Table 1: Yields of silyl ether 2 and 5 and trityl ether 3 and 6, respectively, obtained as described in Scheme 1.

entry	alcohol	reagent	product	yield [%] ^a
1	1a	TBS-Cl	2a	82
2	1b	11	2b	91
3	1c	**	2c	55 "
4	1d	**	2d	37 ⁸
5	4	"	5 ^c	81
6	1a	Ph ₃ CCl	3a	78
7	1b	"	3b	67
8	1¢	"	3c	66 ^{d,e}
9	1d		3d	92 "
10	4	"	6	78 ^g

⁶Yields of isolated product. ⁸30% of the silylphenyl ether was also isolated. ⁶*t*-Butyldimethylsilyl ether at C-7. ⁴Contains 9% of the product mono-tritylated at C-9. ⁶Required longer reaction times (>24 h) for a complete conversion. ⁷Trityl ether at C-3. ⁴Contains 8% of the trityl ether at C-7.

A limitation of this selective protection strategy was the secondary alcohol 1d. Silvl ether formation at the alcohol moiety was accompanied by the attack at the phenol group and, therefore, compound 2d and the corresponding silvlated phenol have been isolated in 37 and 30 %, respectively (entry 4). On the other hand, tritylation of the phenol group of 1d was completely regioselective producing 3d in 92% yield, although a longer reaction time (24 h at room temperature) was required for a complete conversion (entry 9). Kojic acid (4), a heteroaromatic compound, behaves like the phenolic compound 1c. Thus, silvl ether 5 was formed regioisomerically (entry 5) pure in 81% yield, but the trityl ether 6 (78%) was contaminated with 8% of the C-9 monotrityl ether (entry 10).

8% of the trityl ether at C-7. In summary, we have shown that hydroxyalkyl phenols undergo selective protection either at the hydroxy or at the phenol group by simply choosing the protecting reagent under otherwise essentially the same reaction conditions. TBS-CI selectively formed the silyl ether at the alcohol moiety, whereas trityl chloride gave preferentially the phenyl ether.

ACKNOWLEDGEMENT

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- 8. Salicyl alcohol 1b and kojic acid (4) are commercially available. Compound 1c was prepared in three steps from ferulic acid (1. MeOH, H⁺; 2. H₂, Pd/C 10%, 3. LiAlH₄, 80% overall), compound 1a was obtained in 8 steps from 5-bromo-salicylaldehyde according to known procedures (Findlay, J. B. C.; Fishwick, C. W. G.; Kersey, I. D.; Ward, P. Synthesis 1995, 553-556) (30% overall), and 1d by addition of n-BuLi to the same precursor at low temperature (94%).